

# Electronic properties V:Ga-O:N center in GaN and GaInN: GGA+U approach

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Defect complex consisting of cation vacancy and substituting oxygen for N (VO) in GaN [1] is one of the most promising systems for the realization of qubits in semiconductors. Here we analyzed the electronic properties of charged VO in bulk wurtzite GaN and Ga<sub>1-x</sub>In<sub>x</sub>N for x ranging from 0 to 0.1 by GGA +U approach [2,3], including the Hubbard-like term +U applied on p(N) and p(O) orbitals. The VO is in high spin state with spins of 1/2, 1 and 3/2 for -1, 0 and +1 charge state, respectively, for both GaN and GaInN. Our calculations of transition levels of -2/-1 and -1/0 transitions in GaN amount to 1.5 and 1.1 eV relative to the VBM, respectively, which is in line with experiments [1]. Finally, we analyzed the possibility of using VO center in GaN and in GaInN in the context of spin qubit operation.

## References:

- [1] N. T. Son et al., Phys Rev B 80, 153202 (2009), A. Sedhain et al., Appl. Phys. Lett. 96, 151902 (2010).
- [2] M. Cococcioni and S. de Gironcoli, Phys. Rev. B 71, 035105 (2005).
- [3] P. Giannozzi et al. J. Phys.: Condens. Matter. 21, 395502 (2009).

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